

Supplementary Information

Monolayer MoS₂ Bandgap Modulation by Dielectric Environments and Tunable Bandgap Transistors

Junga Ryou¹, Yong-Sung Kim^{1,2,*}, Santosh KC³ & Kyeongjae Cho^{3,*}

¹Korea Research Institute of Standards and Science, Daejeon 305-340, Korea

²Department of Nano Science, University of Science and Technology, Daejeon 305-350, Korea

³Department of Materials Science and Engineering, University of Texas at Dallas, Richardson, TX 75080, USA

* Correspondence to: Y.S.K. (email: yongsung.kim@kriss.re.kr); K.C. (email: kjcho@utdallas.edu).

Methods: GW Calculations with Effective Environmental Dielectric Screening

Based on classical electrostatics, the Poisson equation governing an inhomogeneous dielectric system is

$$\nabla \cdot [\varepsilon^M(\mathbf{r})\nabla V(\mathbf{r})] = -4\pi\rho(\mathbf{r}), \quad (1)$$

where $\rho(\mathbf{r})$ is the charge density, $V(\mathbf{r})$ is the electrostatic potential, and $\varepsilon^M(\mathbf{r})$ is the spatially varying macroscopic dielectric constant. In a periodic system with the lattice vector, \mathbf{R} , the Fourier transform of Eq. (1) is

$$\sum_{\mathbf{G}'} \varepsilon_{\mathbf{G}-\mathbf{G}'}^M \mathbf{G} \cdot \mathbf{G}' V_{\mathbf{G}'} = 4\pi\rho_{\mathbf{G}}, \quad (2)$$

where \mathbf{G} and \mathbf{G}' are the reciprocal lattice vectors. The Eq. 2 can be rewritten as

$$\sum_{\mathbf{G}'} \varepsilon_{\mathbf{G}\mathbf{G}'}^M V_{\mathbf{G}'} = 4\pi\rho_{\mathbf{G}}/G^2, \quad (3)$$

$$\varepsilon_{\mathbf{G}\mathbf{G}'}^M \equiv \varepsilon_{\mathbf{G}-\mathbf{G}'}^M \mathbf{G} \cdot \mathbf{G}' / G^2. \quad (4)$$

Here, we define the macroscopic static dielectric matrix, $\varepsilon_{\mathbf{G}\mathbf{G}'}^M$. On the other hand, the static dielectric matrix $\varepsilon_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0)$ of a system in vacuum is related to its static polarizability $\chi_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0)$ as

$$\varepsilon_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0) = \delta_{\mathbf{G}\mathbf{G}'} - v(\mathbf{q} + \mathbf{G})\chi_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0), \quad (5)$$

where $v(\mathbf{q} + \mathbf{G})$ is the bare Coulomb interaction. When the system is nearby a dielectric media, the additional screening by the dielectrics can be approximated by the macroscopic dielectric polarizability, $\chi_{\mathbf{G}\mathbf{G}'}^M(\mathbf{q}; 0)$. $\chi_{\mathbf{G}\mathbf{G}'}^M(\mathbf{q}; 0)$ is then added to the static polarizability $\chi_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0)$ of the main system of interest:

$$\varepsilon_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0) = \delta_{\mathbf{G}\mathbf{G}'} - v(\mathbf{q} + \mathbf{G})\{\chi_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0) + \chi_{\mathbf{G}\mathbf{G}'}^M(\mathbf{q}; 0)\} \quad (6)$$

$$= \varepsilon_{\mathbf{G}\mathbf{G}'}^M(\mathbf{q}; 0) - v(\mathbf{q} + \mathbf{G})\chi_{\mathbf{G}\mathbf{G}'}(\mathbf{q}; 0). \quad (7)$$

In Eq. 7, the only difference from the static dielectric matrix of Eq. 5 is $\varepsilon_{\mathbf{G}\mathbf{G}'}^{\mathbf{M}}(\mathbf{q}; 0)$ instead of $\delta_{\mathbf{G}\mathbf{G}'}$, which represents that the vacuum is replaced by the dielectric media where the system is located. The $\varepsilon_{\mathbf{G}\mathbf{G}'}^{\mathbf{M}}(\mathbf{q}; 0)$ can be obtained from Eq. 4 for the $|\mathbf{q}\rangle$ electronic state as

$$\begin{aligned}\varepsilon_{\mathbf{G}\mathbf{G}'}^{\mathbf{M}}(\mathbf{q}; 0) &= \varepsilon_{\mathbf{q}+\mathbf{G}, \mathbf{q}+\mathbf{G}'}^{\mathbf{M}} \\ &= \varepsilon_{\mathbf{G}-\mathbf{G}'}^{\mathbf{M}}(\mathbf{q} + \mathbf{G}) \cdot (\mathbf{q} + \mathbf{G}') / |\mathbf{q} + \mathbf{G}|^2.\end{aligned}\quad (8)$$

The real-space macroscopic dielectric constant profiles $[\varepsilon^{\mathbf{M}}(\mathbf{r})]$ along the perpendicular direction to the ML MoS₂ are shown in Fig. S1 for the model structures of (a) the ML MoS₂ with one-side HfO₂, (b) the ML MoS₂ with both-side HfO₂, (c) the ML MoS₂ with one-side Au, and (d) the ML MoS₂ with both-side Au. The dielectric interfaces are chosen to be the top- and bottom-most atomic plane of the HfO₂ and Au slabs. At the interfaces, the dielectric profiles were smoothed with the error functions ($\beta=0.2 \text{ \AA}$).

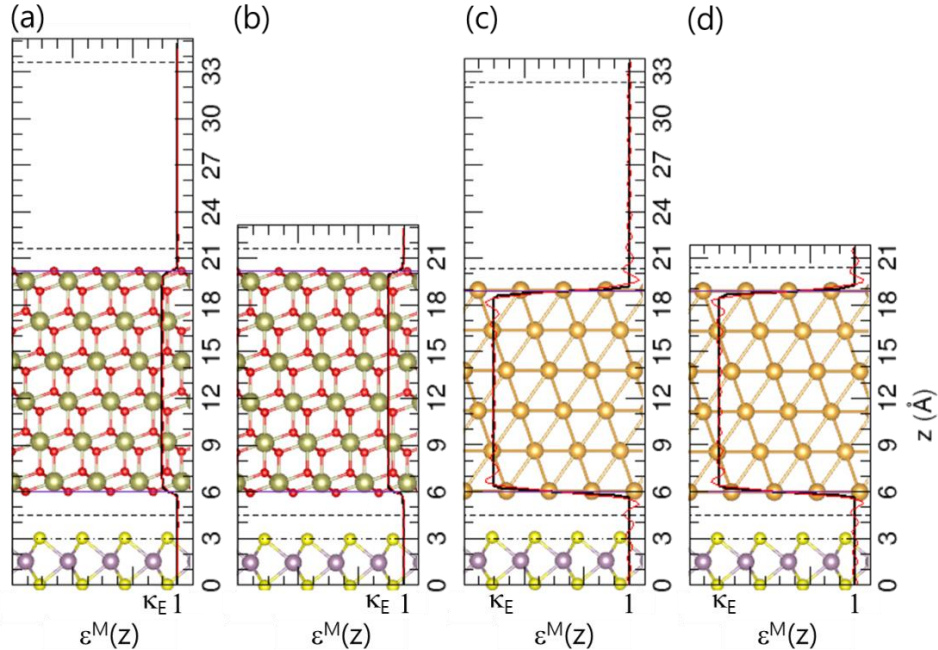


Figure S1. Real-space environmental dielectric constant profiles. (a-d) The dielectric constant profiles along the perpendicular direction to the ML MoS₂ for (a) the ML MoS₂ with

one-side HfO₂, (b) the ML MoS₂ with both-side HfO₂, (c) the ML MoS₂ with one-side Au, and (d) the ML MoS₂ with both-side Au.